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PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Kenji HORI

Group Art Unit: 2873

Application No.: 10/665,568

Examiner: M. Hasan

Filed: September 22, 2003

Docket No.: 111608.01

For: OPTICAL COMPONENT THICKNESS ADJUSTMENT METHOD, OPTICAL COMPONENT, AND POSITION ADJUSTMENT METHOD FOR OPTICAL COMPONENT

APPLICANT'S INTERVIEW SUMMARY

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Applicant thanks Examiners Hasan and Sugarman for the courtesies extended to Applicant's representative during the June 28 personal interview.

During the interview, Applicant's representatives explained distinctions between the features recited in independent claim 5 and U.S. Patent Publication No. 2002/0030898 A1 to Kouchiyama et al. (Kouchiyama) applied in the March 22, 2005 Office Action. Specifically, Applicant's representatives asserted that Kouchiyama teaches that the lens 14 is formed by etching the mask 13. See Figs. 2-5 and paragraphs [0057] - [0064] of Kouchiyama. Thus, Kouchiyama does not teach or suggest etching after manufacturing (providing) the lens as recited in claim 5. The Examiners indicated that they would fully consider and respond to the June 22 Amendment in view of the interview.

Favorable reconsideration and prompt allowance of the application is earnestly solicited. Should the Examiner believe that anything further would be desired in order to place the application in better condition for allowance, the Examiner is invited to contact the undersigned at the telephone number set forth below.

Respectfully submitted,



Mario A. Costantino
Registration No. 33,565

Klifton L. Kime
Registration No. 42,733

MAC:KLK/tls

Date: July 5, 2005

OLIFF & BERRIDGE, PLC
P.O. Box 19928
Alexandria, Virginia 22320
Telephone: (703) 836-6400

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